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Cationic Polymerization (Cure Kinetics) of Model Epoxide Systems

by Reza Dabestani, Ilia N. Ivanov,
and James M. Sands

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Cationic Polymerization (Cure Kinetics) of Model Epoxide Systems

Reza Dabestani and Ilia N. Ivanov
Oak Ridge National Laboratory

James M. Sands
Weapons and Materials Research Directorate, ARL

Abstract

Cationic polymerization of epoxy resins can be induced by ultraviolet (UV) or electron beam (E-beam) radiation and proceeds very efficiently in the presence of an appropriate photoinitiator. Although good thermal properties have been obtained for some E-beam cured epoxy resins, other important mechanical properties, such as interlaminar shear strength, fracture toughness, and compression are poor and do not meet aerospace manufacturers materials standards. We have initiated a comprehensive study to investigate the cure kinetics and mechanisms of UV and E-beam cured cationic polymerization of two epoxide-terminated resins (phenyl glycidyl ether, a monofunctional model compound, and Tactix 123, a difunctional structural resin) cured using a mixed triaryl iodonium hexafluoroantimonate salt (Sartomer's CD-1012) photoinitiator. The objective of this study was to demonstrate that identical reaction conditions and kinetic parameters (e.g., radiation dose, initiator concentration, and reaction temperature) control the physical and chemical properties of final polymeric products, regardless of initiation by UV or E-beam radiation. Additionally, the identification of key parameters that give rise to improved thermal and mechanical properties in E-beam processed resins is sought. Fast kinetic spectroscopy, coupled with high-performance liquid chromatography, was used to elucidate the polymerization mechanism and to identify the reactive intermediates, or molecules, involved in the cure process.

Acknowledgments

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1. Introduction

Currently, there is considerable interest in developing high-strength, lightweight polymer matrix composite materials for the aerospace and automotive industries. One class of resins that have the proper thermal and mechanical properties for these applications is toughened epoxies. These materials are typically processed by thermal (i.e., autoclave) curing methods, but recently, composites with comparable thermal and mechanical properties have been prepared by radiation curing. Ultraviolet (UV) and electron beam (E-beam) curing of resins and composites has received considerable attention in recent years [1–6]. Radiation curing typically uses high-energy radiation from an electron gun to induce polymerization and cross-linking reactions. E-beam curing is of great interest to industry because it has many advantages over thermal-curing methods that include lower cost, improved polymer performance, reduced energy consumption, lower residual thermal stress, reduced volatile toxic by-products, and simpler, less expensive tooling. E-beam processing is currently used for curing thin films for can and beverage coatings, printing inks for folding cartons, and anticorrosion coatings for automobile wheels [7]. Recent advances in E-beam curing of polymers has invoked onium salt promoters in cationic polymerization of vinyl ether monomers [8] and epoxy resins [9].

A fundamental understanding of the chemical events that lead to the desired material properties as well as a knowledge of the materials that undergo these radiation-induced reactions can provide researchers with the insight needed to control properties of the end products and to make advances into the development of novel resin systems for use in composites and adhesive applications. However, there is a lack of understanding concerning the chemical reactions that occur in the radiation curing of polymeric materials and the chemical structures that produce the desired mechanical properties. The goal of this study is to identify and optimize the parameters that control the material properties to facilitate preparation of new composites with advanced mechanical and thermal properties from epoxy resins by radiation curing.

2. Background

Radiation induced cationic polymerization in the presence of an initiator has not been investigated in detail. A plausible mechanism for radiation curing of epoxy resins by cationic polymerization in the presence of onium salts has been

proposed recently to explain the curing process [9]. The assigned intermediates, however, are speculative (not based on experimental evidence), and their rates of reaction to form cross-linked and/or scission products are unknown (Figure 1) [9]. Thus, a basic understanding of the kinetics and mechanisms of radiation curing leading to crosslinking and scission (an undesirable process that can adversely affect the properties of final composite) products is needed to set the criteria for developing application-specific composites.

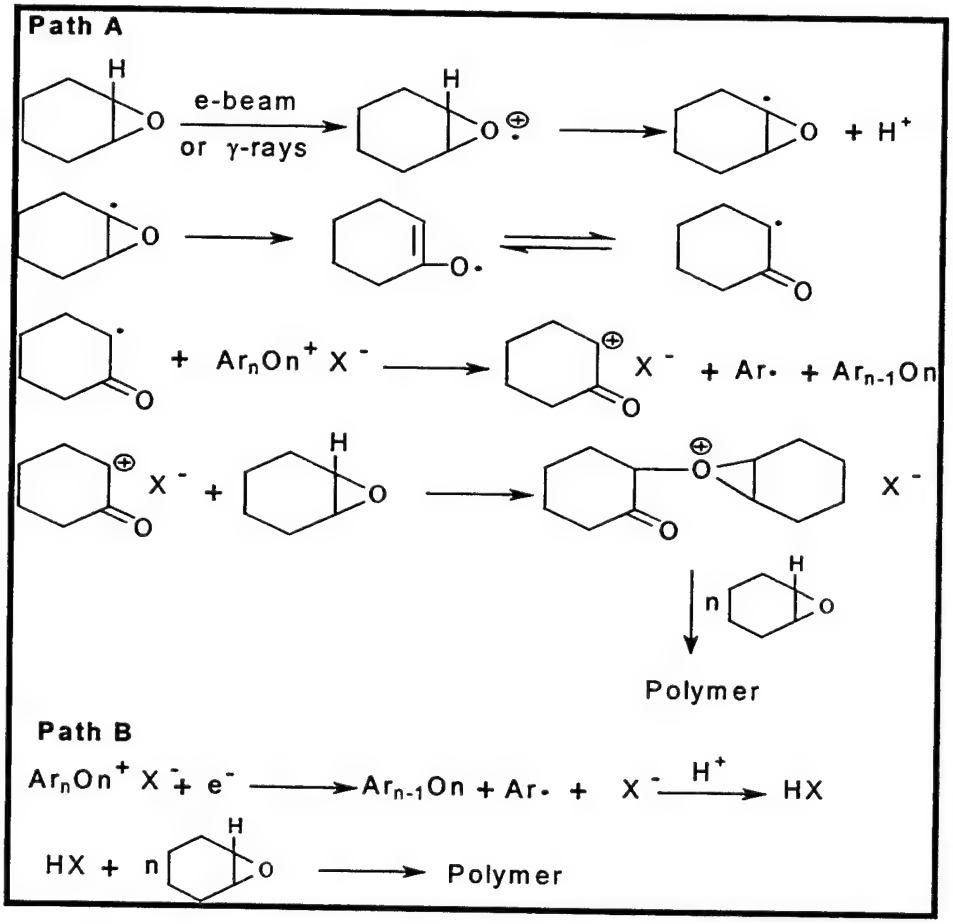

Figure 1. Proposed reaction mechanism for cationic ring-opening of epoxides using E-beam initiation.

We have taken a fundamental approach to investigate the chemistry of radiation curing of phenyl glycidyl ether (PGE) and Tactix 123 as model compounds in the presence of a mixed triaryl iodonium hexafluoroantimonate salt (Sartomer's CD-1012) as the photoinitiator. Insight gained from these experiments should pave the way towards the design and synthesis of novel composites, which will be of significant interest to the defense, aerospace, and transportation industries.

3. Experimental

3.1 Materials

The structure of all the reagents used in this study are shown in Figure 2. All the solvents used were high-performance liquid chromatography (HPLC) grade and include tetrahydrofuran (THF), acetonitrile (ACN), and water. Bromophenol blue (3',3",5',5"-tetrabromophenolsulfonephthalein) was used as received from Aldrich Chemical Company. Gel permeation chromatography (GPC) was performed on a Waters 600E Instrument. HPLC analysis of the samples was carried out under isocratic conditions (75/25 acetonitrile/water) using a Hewlett Packard Model 1090 equipped with a diode array detector set at 254 nm. Absorption spectra of the samples were obtained on a Cary 4 spectrophotometer. Fast kinetic studies using pulse radiolysis were conducted at Notre Dame Radiation Facilities, University of Notre Dame, Notre Dame, IN.

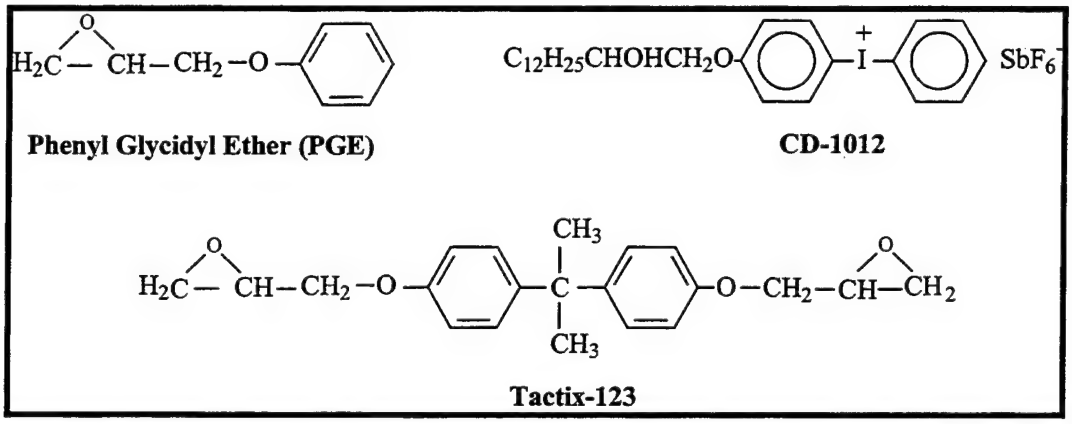

Figure 2. Structures of reagents used to evaluate chemical kinetics.

3.2 Procedure

3.2.1 Sample Preparation and UV-Photolysis

Our initial kinetic studies on UV cationic polymerization of Tactix 123 in the presence of CD-1012 focused on polymerization rate and the nature of polymeric materials formed. Tactix 123 samples were prepared containing 3% by weight CD-1012 in glass tubes (~1 g total weight) and photolyzed in a Rayonet photoreactor using 300-nm excitation light source. After the photolysis, a known volume of THF was added to the irradiated sample to dissolve the low molecular weight polymers, and the mixture was filtered leaving an insoluble material (cross-linked polymer) which was dried and weighed. A portion of the THF

mixture was analyzed by HPLC to determine the loss of Tactix 123 by irradiation. The remaining THF solution was concentrated down and analyzed by GPC to obtain information on low molecular weight polymers formed during photolysis.

3.2.2 Pulse Radiolysis

Time-resolved studies of the intermediates were performed using pulse radiolysis, where excitation was induced using a linear electron accelerator (Model TBS-8/16-1sTitan Beta, Dublin, CA) that generates 1- to 10-ns pulses of 8 MeV. These pulses were used as the excitation source and were delivered to a flow cell containing the sample. Intermediates generated by the electron pulse were detected by optical absorption using a pulsed 1-kW Xe-lamp (samples were in quartz cuvette with a optical path length of 1 cm). All experiments were carried out with a continuously flowing solution. A solution of potassium thiocyanate (10 mM) saturated with nitrous oxide was used as the dosimeter (using radiation chemical yield of 6.13 for a dimer of cyanide anion $(SCN)^{-}_{2}$ and a molar coefficient of 7580 $M^{-1}cm^{-1}$ at 472 nm). The data acquisition system included a Spex 270M monochromator, a LeCroy 7200A digital storage oscilloscope with a 7242 plug-in module and a shielded 5-stage photo-multiplier tube (PMT, Hamamatsu 955). Software program with incorporated multiple time scale stages, developed by G. L. Hug, was used for running the pulse radiolysis experiment [10].

3.2.3 Steady State Radiolysis

Steady state gamma radiolyis studies were performed on two programmable cobalt-60 gamma irradiators with radiation intensities of about 2 and 6 kilo Curies and dose rates of 5 and 20 krad/min, respectively. Samples were placed in capped glass vials. Insignificant increase in the temperature of the sample was observed when the sample was irradiated for a long period of time. After irradiation, samples were analyzed by optical absorption spectroscopy.

4. Results and Discussion

4.1 UV Photolysis of Tactix 123 Containing 3% (Weight) CD-1012

Table 1 shows the data for a set of samples irradiated at various times. As the data in Table 1 shows, the yield of insoluble polymer (crosslinked material) increases with increasing irradiation time and accounts for about 70% of the total polymer formed. Samples irradiated to >90% conversion of Tactix 123 completely solidified and were hard to remove from the glass tube by THF.

Table 1. HPLC and GPC analysis data for the photolysis (300 nm) of Tactix 123 in the presence of CD-1012 as the photoinitiator.

Irradiation Time (min)	Moles Tactix at Time 0	Moles Tactix After Irrad.	% Loss [a] Tactix	% Polymeric Cross-Linked Insoluble Product [b]	%Polymeric Soluble Products[c]
3	2.4 E-3	2.2 E-3	8.8	0.0	100
6	2.6 E-3	2.1 E-3	20.9	19.0	81.0
9	3.1 E-3	1.7 E-3	47.7	22.0	78.0
12	3.0 E-3	1.7 E-3	43.7	56.0	44.0
18	2.8 E-3	1.1 E-3	60.4	67.0	33.0
24	2.7 E-3	9.7 E-4	64.1	69.0	31.0

[a] Data obtained by HPLC.

[b] Percent crosslinked insoluble polymeric product in THF (based on weight).

[c] Percent soluble product based on GPC analysis of dissolved fraction in THF. Three broad peaks eluting at 19, 21, and 24 min (unreacted CD-1012 and Tactix 123 elute at 26 and 29 min, respectively).

As a result, the exact weight of insoluble polymer could not be determined for high-conversion samples. Figure 3 shows a plot of percent loss of Tactix 123 monomer as a function of irradiation time for the data shown in Table 1.

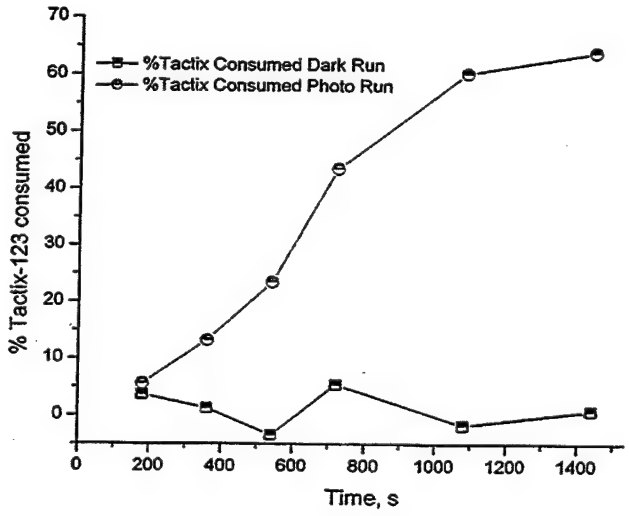

Figure 3. Percent loss of Tactix 123 monomer as a function of irradiation time.

From the plot of $\ln (A/A_0)$ vs. irradiation time (not shown), the first-order rate constant for loss of Tactix 123 was determined to be $k = 7.6 \times 10^{-4}\ s^{-1}$. During the course of photolysis, a small increase in temperature rise was observed. To study the effect of this temperature rise on the reaction rate, we prepared two samples of Tactix 123 without CD-1012 (set A) and two samples of Tactix 123

with CD-1012 (set B). In one experiment, one sample of set A and one of B were placed in a water bath at 25 °C. A thermocouple was placed inside each reaction mixture to monitor the temperature change during irradiation. Sample B was irradiated for a total of 240 s, while sample A was irradiated for 500 s. The rise in temperature as a function of irradiation time was recorded for both materials (Figure 4), and the loss of Tactix 123 monomer was determined by HPLC for each irradiated sample.

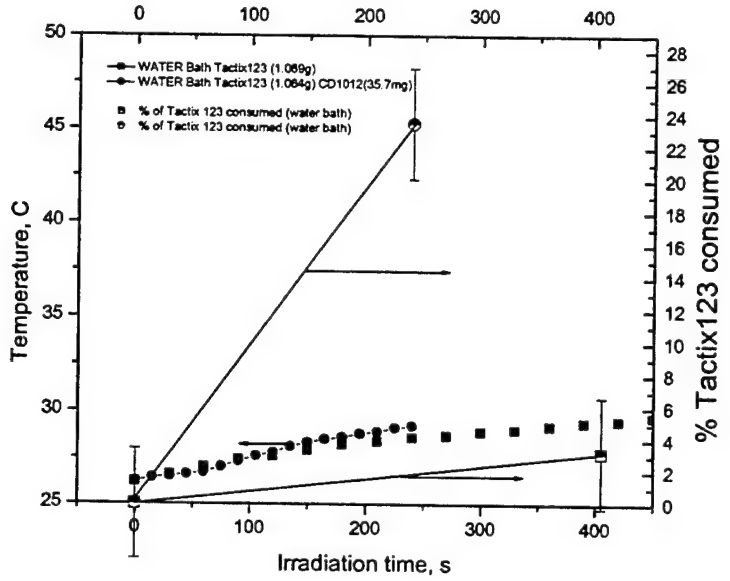

Figure 4. Rise in temperature as a function of irradiation time for Tactix 123 with CD-1012 and without CD-1012.

Because Tactix 123 without CD-1012 does not react, as demonstrated in Figure 3, the observed variance (±5%) is the expected experimental error using the HPLC method of postirradiation analysis. Tactix 123 containing CD-1012 lost about 26% ± 5% in 600 s. The rise in temperature during irradiation for Tactix without CD-1012 was about 3 °C, which we attribute to lamp heating. For Tactix 123 with CD-1012, about 5 °C (Figure 4) rise in temperature was observed. Taking into account the 3 °C rise in temperature due to lamp heating, the rise in temperature as a result of bond breaking (internal temperature rise) during the reaction is only +2 °C. Therefore, we believe that the water bath and small sample size essentially allow for isothermal cure conditions to be maintained.

The same experiment was carried out for the second set of samples in air, allowing heat of reaction to cause appreciable changes in temperature. The results are shown in Figure 5. Observed temperature and extent of Tactix 123 conversion are plotted as a function of irradiation time. The rise in temperature during irradiation for the set A sample was +10 °C, and because no reaction occurs, this is attributed to thermal absorption from the UV excitation lamp. For

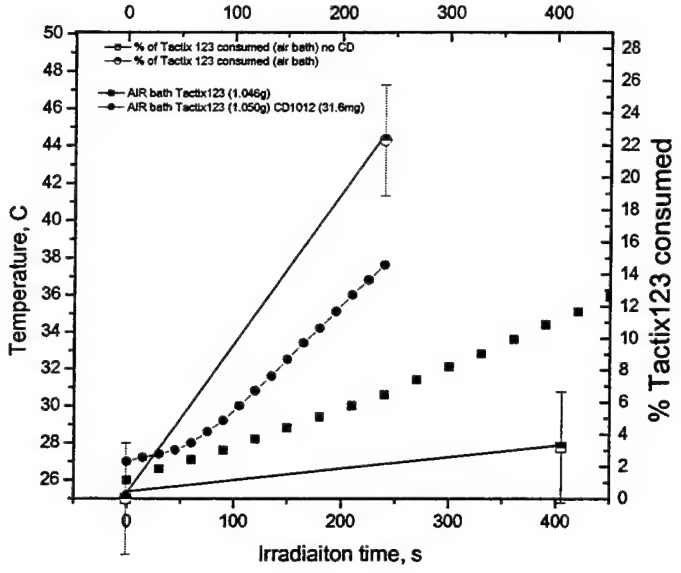

Figure 5. Observed temperature and extent of Tactix 123 conversion.

the set B sample, the temperature rise was +21 °C, or a reaction temperature induced change of +11 °C, resulting from breaking chemical bonds. THF extraction and HPLC analysis of the irradiated sample showed a 23% ±5% conversion of Tactix 123 in 240 s (Figure 5). Comparison of the results for water bath vs. atmospheric irradiation demonstrate that within experimental detection limits, the internal rise in temperature induced during photolysis does not lead to a rate enhancement during photolysis measurements.

The effect of external temperature on the reaction rate was also studied for samples of Tactix 123 with CD-1012 to obtain the activation energy, E_a, and the Arrhenius A-factor for the polymerization process. Figure 6 shows the Arrhenius plot for the change in rate constant as a function of inverse temperature for the photolysis of Tactix 123 with CD-1012. From the slope and intercept of this plot, we obtain an activation energy of 61 kJ/mol and an Arrhenius-A factor of 2.4×10^8 s^{-1}. The observed deviation of reaction rate at higher temperatures (T > 60 °C) could be due to faster molecular diffusion that could facilitate recombination of reactive species back to starting material.

According to Figure 1, polymerization of the epoxy resins proceeds by the interaction of electrons with the monomer (path A) or photoinitiator (path B). In order to determine the extent to which each path (if any) contributes to the polymerization process, we carried out pulse radiolysis experiments on PGE (a model compound that upon polymerization forms soluble products), CD-1012, and PGE/CD-1012 mixtures to obtain information on the nature of intermediates produced in each case.

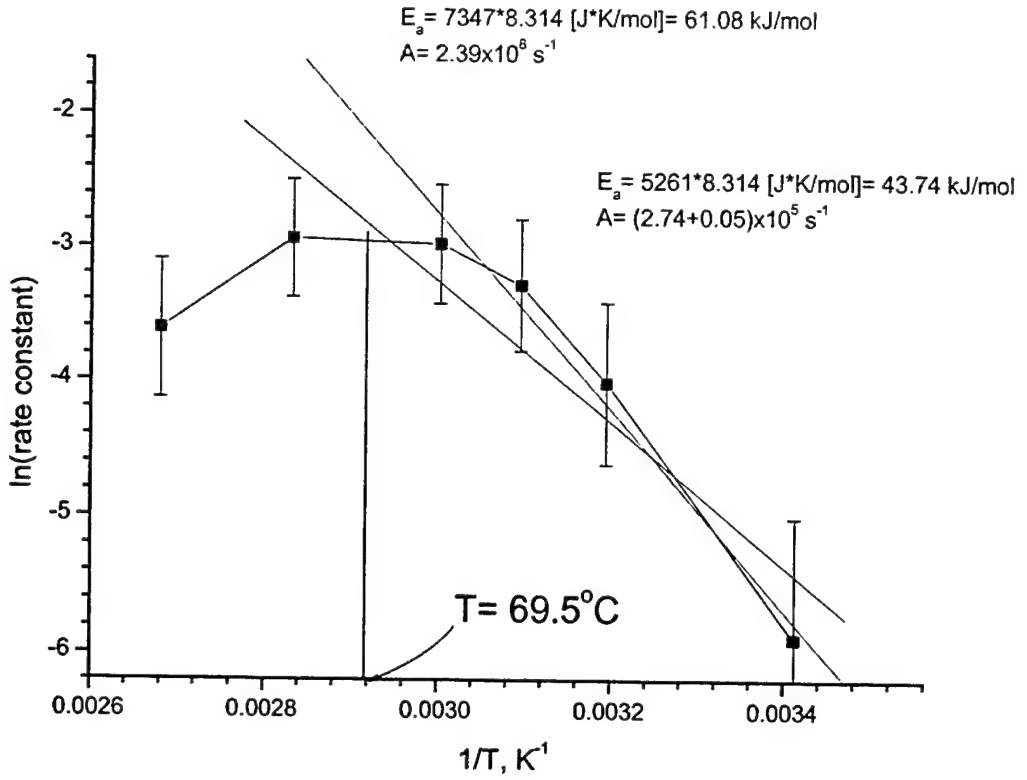

Figure 6. Change in rate constant as a function of inverse temperature for the photolysis of Tactix 123 with CD-1012.

4.2 Steady State γ-Radiolysis

Radiolysis of CD-1012 in aerated acetonitrile was monitored directly by following changes in the absorption spectrum of the solution using nonirradiated acetonitrile as a reference. At low dose rates (5 krad/min), changes in the absorption spectrum of CD-1012 indicate the presence of two isosbestic points observed at 309 nm and 351 nm (Figure 7). As the absorbed dose increases, the absorption in the 200- to 250-nm region of the spectrum increases concomitant with a decrease in the 300- to 400-nm wavelength region. At higher dose rates (20 krad/min), no isosbestic points are observed, and an overall increase in the absorbance is observed (Figure 8). Changes in the intensity of the 234-nm absorption band for CD-1012 with time, upon steady state γ-radiolysis of 70-μM solution of CD-1012 in aerated acetonitrile for two different dose rates (5 and 20 krad/min), is shown in Figure 9. It can be seen from Figure 9 that high dose rates significantly increase the rate of growth for the 234-nm band compared to low dose rates. The 234-nm absorbance almost doubled after exposing the solution for 25 min at 20 krad/min dose rate, while irradiation for 115 min at lower dose rate (5 krad/min) resulted in *ca.* 72%

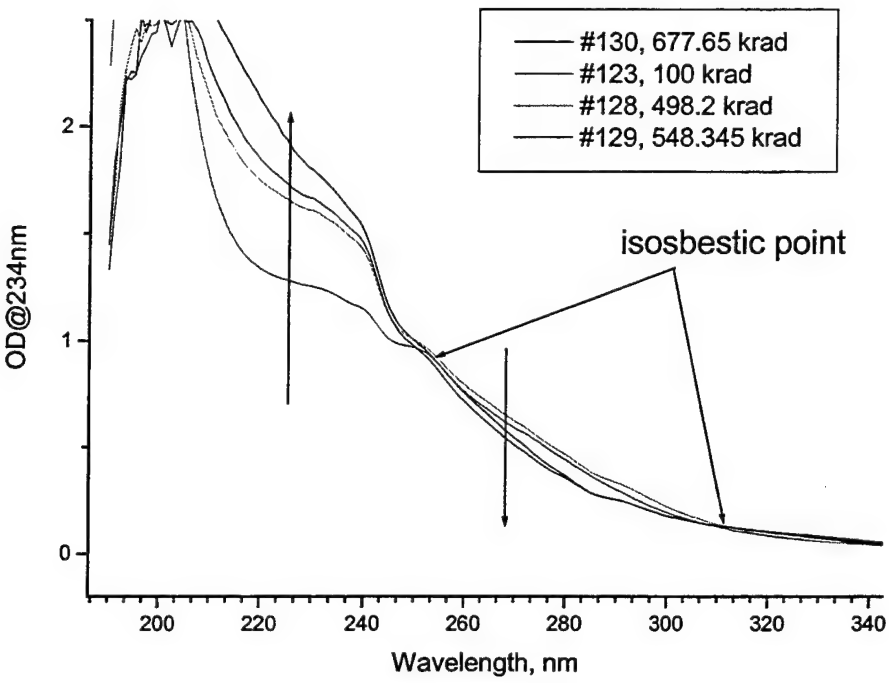

Figure 7. Changes in the UV-Vis absorption spectrum of CD-1012 (70 μmol/L) in aerated acetonitrile observed upon γ-radiolysis (5 krad/min dose rate).

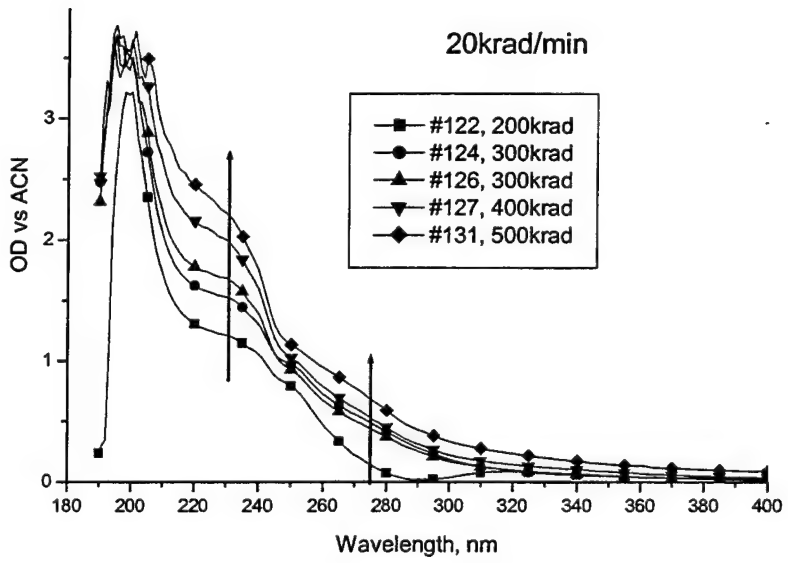

Figure 8. Changes in the UV-Vis absorption spectrum of CD-1012 (70 μmol/L) in aerated acetonitrile observed upon γ-radiolysis (20-krad/min dose rate).

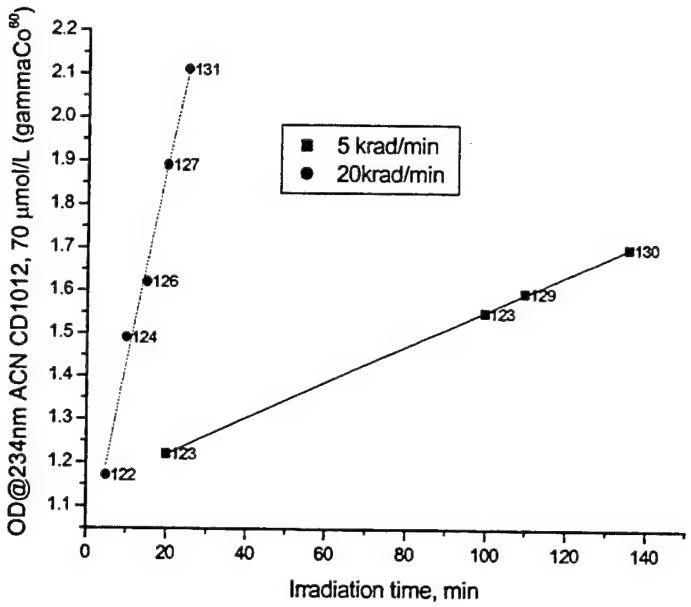

Figure 9. Changes in the intensity of 234-nm absorption band of CD-1012 (aerated 70-µM solution in acetonitrile) with time upon steady state γ-radiolysis (dose rates: 5 and 20 krad/min).

increase in the absorbance. The difference in the rates of growth for 234-nm band under high and low dose rates is a factor of 116, which is much greater than the factor of 4 increase in dose rate. If the observed changes in UV-Vis region of the spectrum are due to formation of the same species (e.g., a precursor to superacid), then at high dose rates, one should produce much more superacid according to the sequence of the reactions shown in Figure 2.

Formation of superacid was monitored by adding bromophenol blue indicator to the irradiated samples of CD-1012. In order to avoid interference from bromophenol blue radiation chemistry with that of CD-1012, the indicator was added after irradiation to a diluted solution of CD-1012 in acetonitrile. An increase in the acidity of the media should result in a decrease in the intensity of the 595-nm absorption band of the bromophenol blue indicator. The change in bromophenol blue absorbance at 595 nm caused by a decrease in the pH of the mixture as a result of radiolytic decomposition of CD-1012 is shown in Figure 10. The data confirms the formation of protons by CD-1012 radiolysis. For high dose rates (20 krad/min), the decrease in the 595-nm absorbance is smaller (almost by a factor of 2) than that for the low dose rate. One possible explanation for this observation is that the yield of superacid precursor (solvent-SbF_6 ion pair or SbF_6^-) decreases at a high dose rate. A decrease in superacid precursor is likely, provided recombination reactions lead to the formation of an intermediate incapable of generating superacid. The changes in the 595-nm absorption appears to be insensitive to the dose rate.

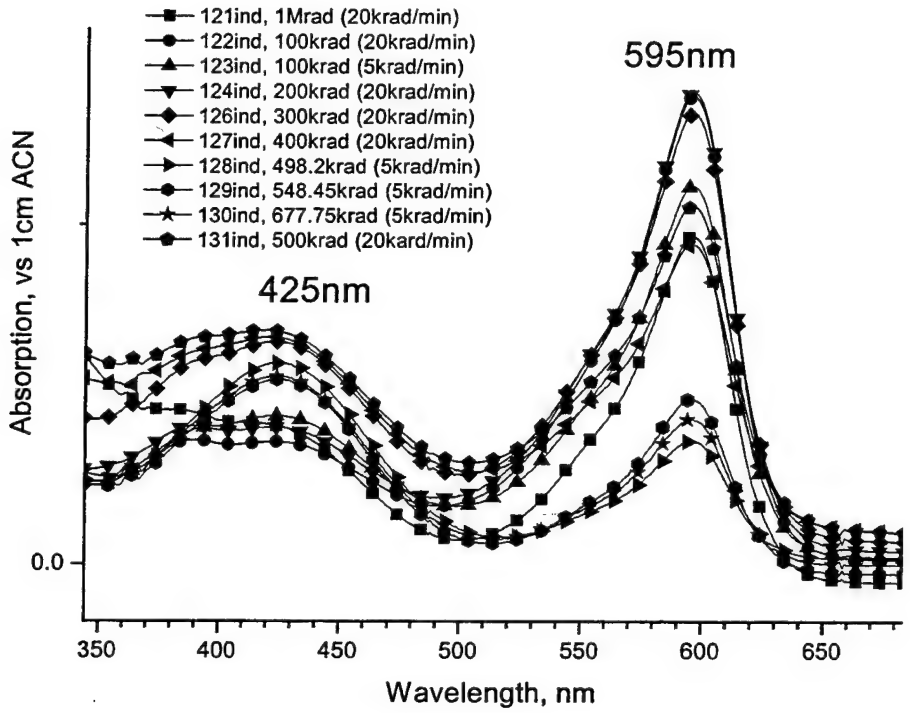

Figure 10. Changes in the UV-Vis absorption spectra of bromophenol blue (35 μmol/L) added to an irradiated (5 and 20 krad/min, blue and black curves) solution of CD-1012 (70 μmol/g) in aerated acetonitrile.

4.3 Pulse Radiolysis of Degassed PGE

Decay of the transient absorption spectrum obtained upon pulse radiolysis of degassed PGE is shown in Figure 11. The transient spectrum observed 0.5 μs after the electron pulse exhibits peaks at 300, 333 (sh), and 400 nm. The 333-nm absorption is buried under the intense 300-nm band and appears at 0.5 μs after the pulse as a shoulder. A broader band with intensity much smaller than that of 300 nm is observed in the 400- to 500-nm wavelength region. The transient spectrum changes significantly 3.0 μs after the pulse. Most of the spectral features, however, resemble the spectrum observed at 0.5 μs after the pulse, except for a broad band. At longer times (>50 μs), the transient spectrum does not change significantly. On the basis of the observed transient spectra, it is clear that the major absorption band (300 nm) corresponds to the first intermediate formed and the broad bands at 400 nm and higher to a second intermediate. Assuming that the spectral features of LLI are the same throughout the observed time scale and that the 300-nm absorption band is mostly due to this species, we can deduce the spectral features of the second

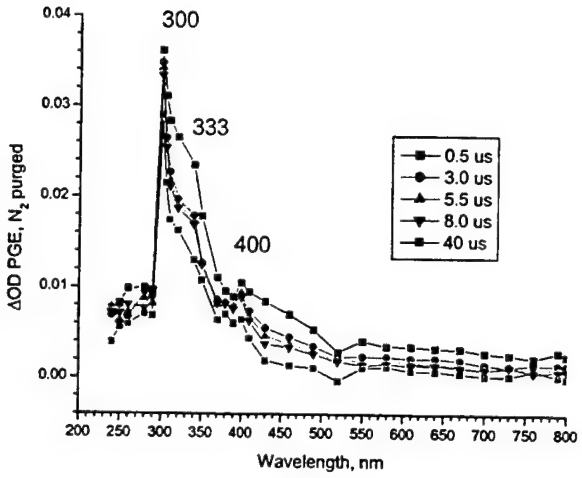

Figure 11. Transient absorption spectrum of nitrogen saturated PGE obtained at 0.5, 3.0, 5.5, 8.0, and 40 μs after the pulse.

intermediate by subtracting the normalized spectrum obtained at 160 μs after the pulse from the normalized spectrum obtained at 0.5 μs after the pulse (both spectra normalized at 300 nm) (Figure 12). The subtracted spectrum representing the second intermediate exhibits absorption bands at 310, 340, and 430 nm, respectively. The complex nature of this transient can be seen in Figure 13, with time profiles of optical density monitored at the major absorption bands 300, 340, 400, and 430 nm. Thus, the 300-nm absorbance attributed to the first intermediate appears to be within the pulse duration (10 ns) of our instrument and continues to grow with a lifetime (τ) of 1.56 ± 0.27 μs (nonlinear least squares fitting procedures with Levenberg-Marquardt algorithm was used). Continuous formation of the 300-nm absorption due to first intermediate appears to be concomitant with the decay of the 430-nm band of second intermediate. The decay profiles could not be fitted to a mono-exponential equation, suggesting the presence of more than one component in these transients. Two-exponential fit of 430-nm decay gave two lifetimes of 4.88 ± 0.45 μs and 60.0 ± 3.4 μs (indicative of the presence of two components), respectively. Decay of the 300-nm absorption band, using the two-exponential model, gave two lifetimes of 3.62 ± 0.79 and 70.0 ± 1.1 μs (also suggesting the presence of two components in this intermediate), respectively. If the first lifetime of the 430-nm band (second intermediate) is kept constant at 3.62 μs, the second component lifetime is estimated to be 60.0 ± 0.8 μs. When the second component lifetime of 430-nm intermediate is restricted to 70 μs, the first component lifetime of 8.19 ± 0.52 μs is obtained. Because the first and second intermediates were observed right after the excitation pulse, it is reasonable to assume that their precursor is either a PGE cation radical or solvated electron (*vida infra*).

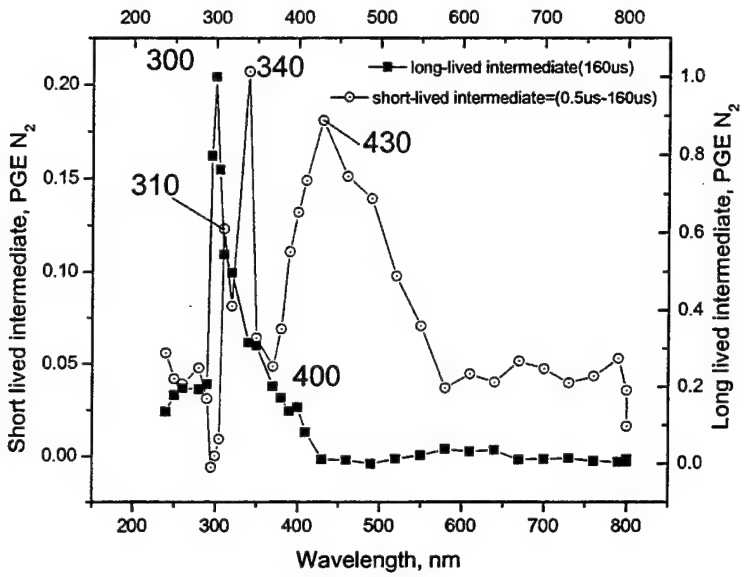

Figure 12. Transient absorption spectra of short-lived and long-lived intermediates obtained upon pulse radiolysis of PGE. The spectrum of the short-lived intermediate was determined by subtracting the spectrum of the long-lived intermediate (taken 160 μs after the pulse) from the spectrum obtained at 0.5 μs after the pulse.

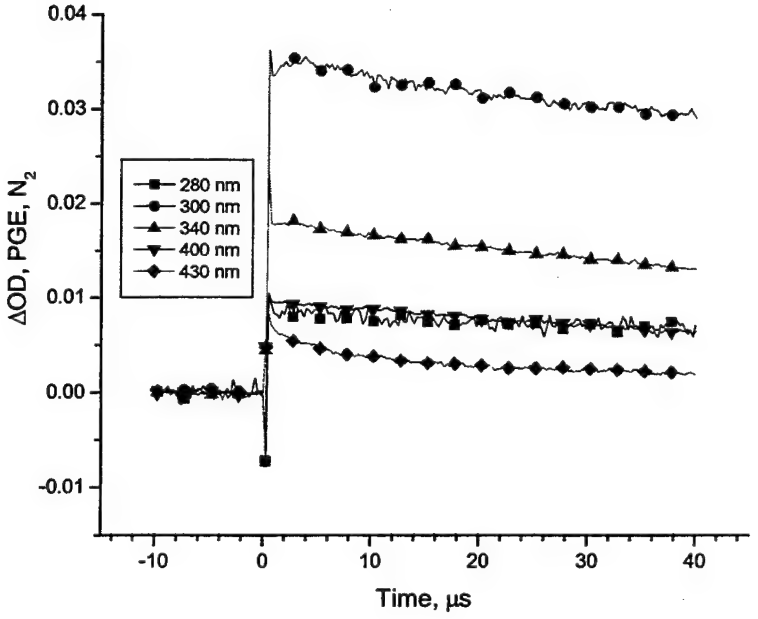

Figure 13. Changes in the optical density at major absorption bands (280, 300, 340, 400, and 430 nm) obtained upon pulse radiolysis of degassed PGE.

4.4 Pulse Radiolysis of Oxygenated PGE

The major absorption bands in the transient absorption spectrum of oxygenated PGE obtained 0.5 μs after the pulse are similar to those found for degassed PGE (300, 340 [sh], 400 and 425 nm) (Figure 14). A decrease (factor of 1.5) in the initial intensity of the 340-nm absorption band is observed compared to degassed PGE. This shoulder was previously attributed to the spectral signature of a second intermediate. Oxygen does not quench SLI completely, and similar to degassed PGE, we observe a significant difference between the 0.5- and 3.0-μs spectra indicative of the presence of this intermediate. The spectrum of this intermediate shows features that are quite similar to that observed in degassed PGE with the major absorption bands at 310, 340, and 425 nm. The difference between these spectra is in the relative band intensities. Oxygen appears to quench the 340-nm band of this intermediate, as well as the narrow band at 430 nm. This observation, coupled with the fact that oxygen does not affect the spectral features of the first intermediate (300-nm band), suggests that the second intermediate has a complex nature and that its spectrum consists of at least two components (with different sensitivity to oxygen). The absorption band at 340 nm belongs to the oxygen-sensitive, short-lived component, while the oxygen-sensitive component shows a broad absorption band at 425 nm. A 5-nm blue shift in the position of the 430-nm absorption band in the oxygen-purged PGE compared to the degassed sample could be due to significant overlap of the absorption spectra of for these two components in the absence of oxygen. All the intermediates are formed right after the pulse. Kinetic profiles do not show additional rise in the 300-nm absorption band for the first intermediate at the expense of the 425-nm band of the second intermediate. This suggests that the oxygen-sensitive component of the second intermediate is a plausible precursor for additional formation of the first intermediate in deoxygenated PGE.

4.5 Pulse Radiolysis of N_2O Saturated PGE

In N_2O saturated PGE, solvated electrons can interact with N_2O to produce hydroxy radicals according to equation (1):

$$\bar{e}_{solv} + N_2O + PGE \rightarrow N_2 + OH^{\bullet} + OH^{-}. \qquad (1)$$

Hydroxy radicals could potentially attack the ether or epoxy group of the PGE, causing a change in the UV-Vis absorption spectrum of intermediates. The transient absorption spectrum of PGE saturated with nitrous oxide measured at 0.5, 3.0, 5.5, 8.0, and 40 μs after the electron pulse is shown in Figure 15. Spectral features and relative band intensities are similar to the transient absorption spectrum of degassed PGE with the maxima at 300, 340(sh), 400, and 425 nm, and a broad absorption band in the 450- to 750-nm region. The spectrum of the second intermediate is deduced by subtracting the transient spectrum obtained 200 μs after the pulse from that obtained 0.5 μs after the pulse (both normalized

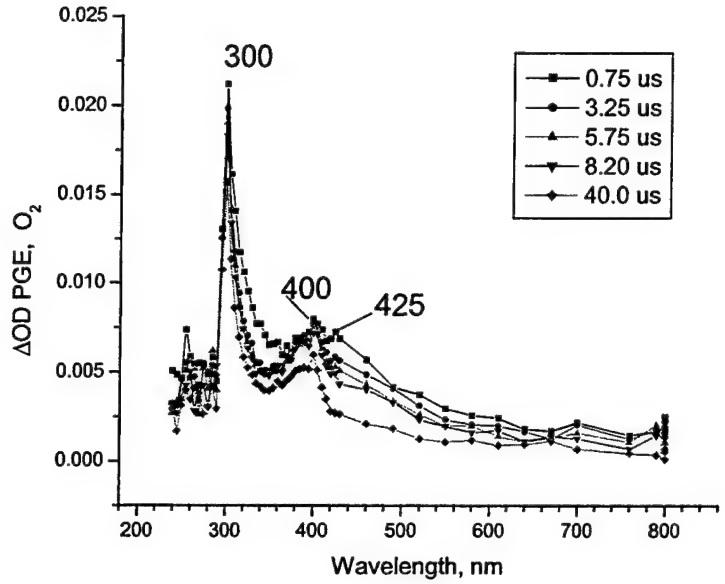

Figure 14. Transient absorption spectra of oxygen saturated PGE taken at 0.75, 3.25, 5.75, 8.20, and 40 μs after the pulse.

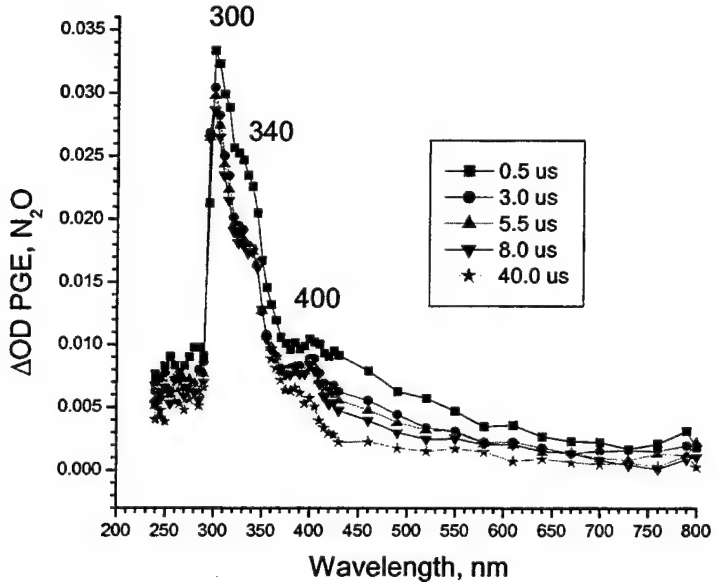

Figure 15. Transient absorption spectra of N_2O saturated PGE taken at 0.5, 3.0, 5.5, 8.0, and 40 μs after the pulse.

at 300 nm). The difference spectrum shows maxima at 330 and 425 nm and a shoulder at 520 nm. Relative intensity of the 330-nm absorption band (compared to that at 425 nm) in the spectrum of this intermediate falls between the values for degassed and oxygen-saturated solution. Similar to degassed PGE, the 300-nm kinetic shows a rise of absorbance within the first few microseconds after the pulse (0.75 ± 0.10 μs), followed by its decay, to give much longer lifetimes of 8.65 ± 0.95 and 90 ± 3.92 μs for its two components. The 425-nm absorbance decays to give a short component lifetime of 0.97 ± 0.11 μs (which is close to the risetime of the 300-nm absorbance) and a relatively slow second component with a lifetime of 70 μs. Similar to the deoxygenated PGE, post-pulse formation of the 300-nm absorbance takes place at the expense of the 425 nm band. The long-lived component of the 340-nm band decays with a lifetime of 70 μs, and the short-lived component decays with a lifetime of 1 μs. Most of the absorbance decays for the second intermediate shows a long-lived component with a lifetime of ca. 70 μs (limited to 200-μs time scale with a pulse-lamp). Based on these results, the range of lifetimes for the long-lived component is 70–90 μs.

4.6 Assignment of Intermediates

Figure 16 depicts plausible intermediates produced by pulse radiolysis of PGE, labeled (1) in that figure. We observe no changes in the initial yield of the intermediates in the presence of N_2O, suggesting that solvated electrons do not play a significant role in their production. Thus, a cation radical of PGE appears to be the most suitable precursor for the formation of all the intermediates observed in the 0- to 200-μs time scale with absorption in the range of 250–800 nm. A cation radical can form by either the ether oxygen or the epoxy oxygen of the PGE. The opening of the epoxy ring is more favorable (releasing 112 kJ of energy) than cleavage of an ether bond (25.3 vs. 44.0 kcal/mol). Therefore, the observed transients are most likely formed by this ring-opening process and can proceed by both paths shown in Figure 16. Loss of a secondary or tertiary proton on the carbon atom adjacent to the epoxide oxygen produces free radical species 4 and 4a. Cleavage of the carbon-oxygen bond is followed by the rearrangement of free radical species to give the resonance stabilized radicals 9, 10 and 9a, 10a. Resonance-stabilized intermediates 9, 10 and 9a, 10a could be assigned to the transient absorption of the first intermediate. Equilibration between the resonance forms of LLI appears to be so fast that we cannot distinguish between them under the conditions of our experiment. However, the presence of more than one lifetime, when fitting these transient absorbances, suggests that several species with relatively similar structures are present. Spectral features of the first intermediate (strong absorption at 300 nm and weaker absorption bands in the 400- to 500-nm wavelength region) agree well with the published spectral characteristics of aromatic ketyl radicals. This notion is further supported by the fact that oxygen does not quench these intermediates.

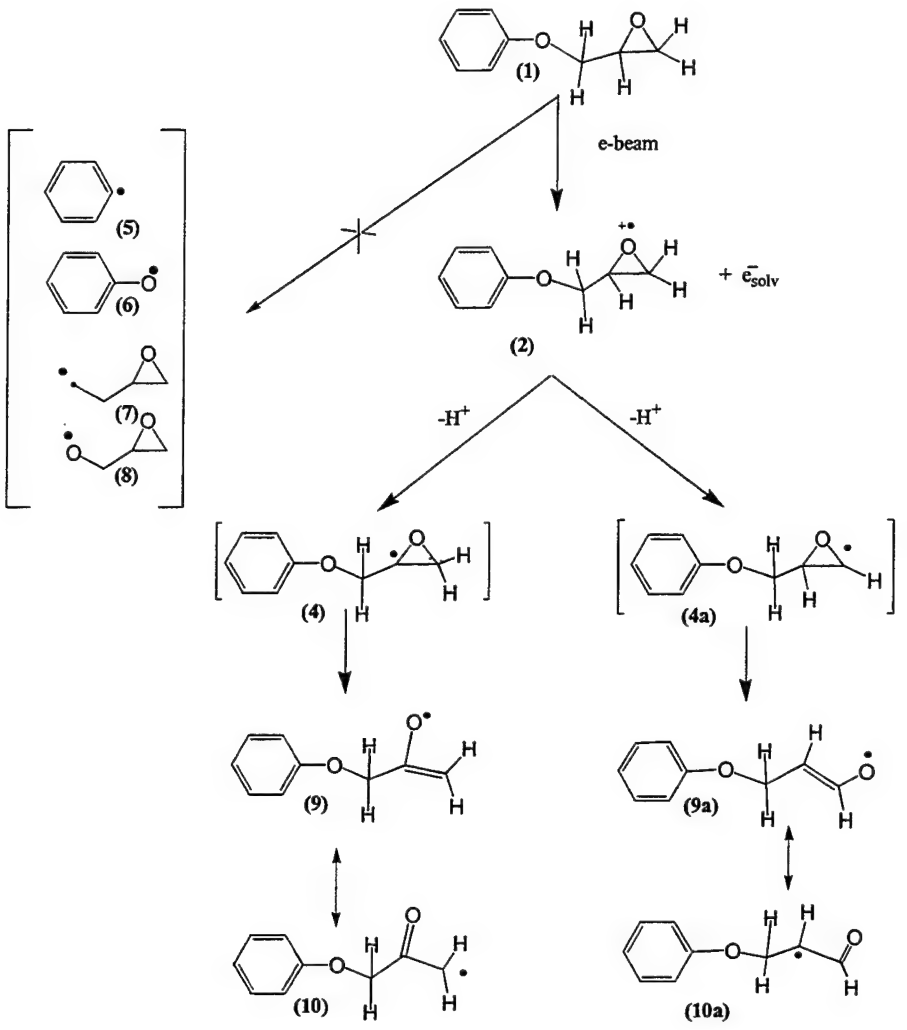

Figure 16. Plausible intermediates produced by pulse radiolysis of PGE.

Additional formation of this intermediate from the oxygen-sensitive component of the second intermediate is observed for all solutions, except for oxygen-saturated ones. Quenching of the oxygen-sensitive component of the second intermediate by oxygen suggests that it is a carbon-centered radical species (with no ketyl character). Intermediates 4 and 4a match these conditions for the oxygen-sensitive transient. The second short-lived component, which is not oxygen sensitive, absorbs at a longer wavelength than the oxygen-sensitive one and could form from the cleavage of epoxy ring. The fact that this component is not quenched by oxygen suggests that it is a zwitterionic species. Hence, intermediate 2 with its ionic character is a plausible candidate. The spectral features of the first and second intermediates, which absorb at a much longer wavelength than any of the possible radicals 5–8 shown in Figure 16, substantiate our proposed mechanism that the PGE ether linkage remains intact upon pulse

radiolysis. Radicals 5–8, which are derived from the homolytic cleavage of ether bond in PGE, where extended conjugation with the phenyl moiety is lost, will absorb at shorter wavelengths.

4.7 Pulse Radiolysis of Degassed PGE Containing 3% (Weight) CD-1012

The evolution and decay of the transient absorption spectrum of degassed PGE in the presence of 3 weight-percent CD-1012 is shown in Figures 17(a) and 17(b). The spectral features of the intermediate with maxima at 360 and 400 nm changes with time. Growth of the 400 nm absorbance maximizes in approximately 11 μs after the pulse and decays on a much longer time scale. Figure 17(b) shows that at longer times (>20 μs after the pulse), the 435-nm band becomes a major absorption band in the transient spectrum and decays on a much longer time scale. About one third of the transient spectrum decayed within 160 μs (limits of pulsed probe lamp). Similar spectral changes were also observed for the transient in the 500- to 800-nm wavelength region (not shown). This transient exhibits a maximum absorption at λ_{max} > 800 nm and two shoulders at 605 and 685 nm (not shown). Spectral features of these intermediates change with time. At 160 μs after the pulse, only the spectrum of transient with λ_{max} > 800 nm is still observed.

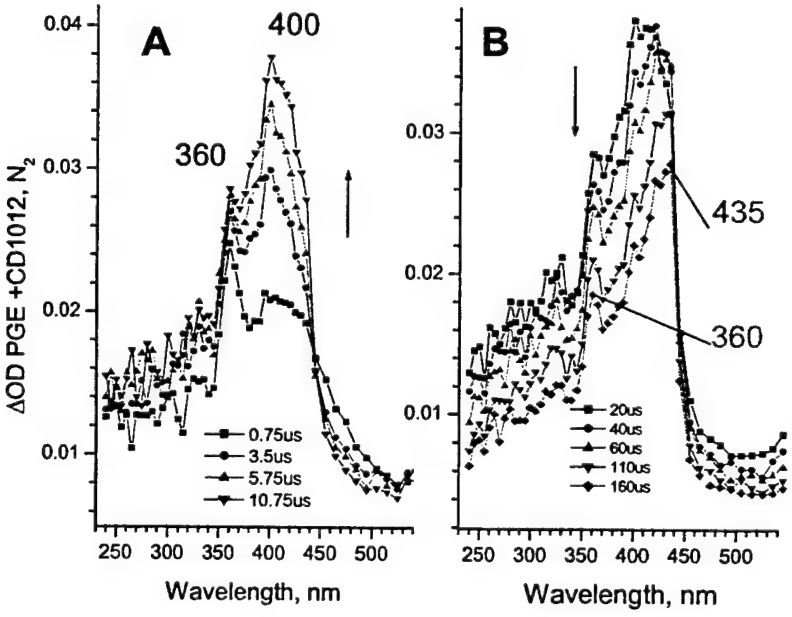

Figure 17. Transient absorption spectrum of degassed PGE in the presence of *ca.* 3% CD-1012 taken at (a) 0.75, 3.5, 5.75, and 10.75 μs and at (b) 20, 40, 60, 110, and 160 μs after the excitation pulse.

We observe significant variation in the risetime of transients (e.g., from 2 μs for 605-nm absorbance to 20 μs for 435-nm band). Almost all the absorption bands reach their maximum value between 20 and 60 μs after the pulse, suggesting that these transients are formed by secondary processes.

4.8 Tentative Assignment of Intermediates Observed on Pulse Radiolysis of Degassed PGE Containing 3% (Weight) CD-1012

None of the transients previously assigned to the first intermediate (9, 9a, 10, and 10a in Figure 16) were observed in the pulse radiolysis of PGE containing 3% CD-1012. Such observation suggests that at this concentration of CD-1012, all PGE intermediates are intercepted by CD-1012, leading to the observed transients. Additional intermediates are produced by the reduction of iodonium salt with solvated electrons (Figure 18). Products of this reaction are an aryl radical (13), hexafluoroantimonate anion (14), and an aryl iodide (12). A strong Brönsted acid, $HSbF_6$ (15), is also generated upon hydrogen abstraction from the PGE molecule by hexafluoroantimonate anion (14). The polymerization reaction shown in Figure 18 proceeds through the reduction of iodonium salt, Ar_2ISbF_6, by either radicals 9, 9a, 10, 10a in Figure 16, or by the solvated electrons producing the intermediates 11 and 11a. The products of this reaction are an aryl radical 13, hexafluoroantimonate anion 14, and an aryl iodide 12. The aryl radical 13 could abstract a hydrogen atom from a molecule of PGE 1 to produce intermediates 4 and 4a, which can proceed to form polymer according to the scheme in Figure 18. Alternatively, the acid-catalyzed ring-opening of the epoxy proceeds through intermediate 16, which has 14 as a counter ion. Ring-opening can take place to generate two different intermediates, 17 and 17a. Interaction of a PGE molecule with either 17 or 17a can produce intermediates 18 or 19, starting a repeating unit of polyphenylglycidyl ether (PPGE).

The observed absorption in the 300- to 600-nm region can be assigned to either intermediates 11 and 11a, or intermediates 17 and 17a with 14 as a counter ion. However, the fact that there is no significant absorbance in the 300-nm region, where ketyl intermediate absorbs, suggests that intermediate 17 is the most likely candidate. It also indicates that initiation of cationic polymerization by PGE radicals is not very efficient compared to polymerization initiated by the reaction of CD-1012 with solvated electrons. The broad absorption band around 605 nm could be attributed to the absorption of diaryliodonium radical cation based on the literature data. It is also plausible that the radiolysis of PGE in the presence of 3% CD-1012 does not proceed to give the first intermediate (9, 9a, 10, and 10a in Figure 16). The precursor of this intermediate, which is the oxygen-sensitive component of the second intermediate, reduces CD-1012, producing the same combination of intermediates 12, 13, and 14, as well as ring-opening of the epoxy ring without the formation of a ketyl intermediate. This is consistent with our experimental observation that the observed transient obtained at 0.75 μs after the

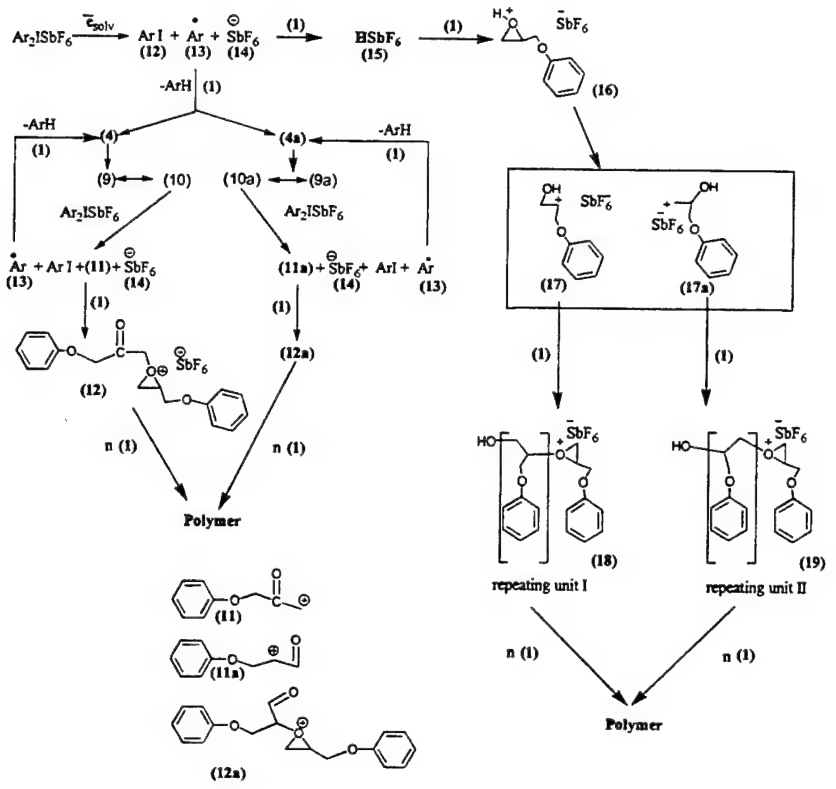

Figure 18. Plausible intermediates produced by pulse radiolysis of 3% CD-1012 in degassed PGE.

pulse (for PGE + CD-1012 mixture) shows no spectral features of the first intermediate. Table 2 summarizes the spectral features and lifetimes of these intermediates and their components.

Table 2. Spectral features and the lifetime of intermediates observed for PGE and PGE/CD-1012 by pulse radiolysis.

Transients Observed	CD-1012 Present	Components Present	Absorption Peaks Observed (nm)	Quenched by Oxygen	Observed Lifetimes
1	No	1	300 (sharp), 400 (shoulder), 450–700 (broad)	No	3.6–8.6 μs, 70–90 μs
2	No	2	340 (sharp), 430 (sharp)	Yes No	1, 70 μs, 1–5 μs, 60–70 μs
1	Yes	ND[a]	360 (sharp), 400 (sharp), 500-800 (broad)	ND[a]	ND[a]

[a] Not determined.

5. Conclusions

UV photolysis of Tactix 123 in the presence of photoinitiator CD-1012 (3% by weight) proceeds efficiently to produce mainly a cross-linked insoluble polymer. The first-order reaction rate for the polymerization process ($k_1 = 7.6 \times 10^{-4}$ s^{-1}) appears to be insensitive to temperature. An activation energy of 61 kJ/mole was determined for the polymerization process.

Kinetics of PGE polymerization by pulse radiolysis has revealed that upon excitation, PGE produces two intermediates that absorb in the UV-Vis region of the spectrum. The first intermediate shows a strong absorption band at 300 nm. The second intermediate that absorbs above 400 nm contains two short-lived components—one sensitive and the other insensitive to oxygen. The rise time of these components is about 2 μs. It appears that decomposition of the oxygen-sensitive component results in the production of additional amounts of first intermediate that absorbs at 300 nm. Based on our kinetic data, we have assigned two plausible structures to these components. The oxygen-sensitive intermediate can form by a PGE radical after abstraction of a hydrogen atom from one of the carbon atoms of the epoxy moiety without ring opening (4 and 4a in Figure 16). The oxygen-insensitive component can form as a zwitterionic species (2 in Figure 16). The components of first intermediate can be assigned to two ketyl radicals, 9 and 9a (Figure 16), which are in equilibrium with their resonance forms, 10 and 10a (Figure 16). All the intermediates produced upon pulse radiolysis of PGE under different reaction conditions (oxygen, nitrogen, and nitrous oxide saturated) seem to derive from the cation radical of PGE. Solvated electrons do not produce any intermediate that absorbs in the UV-Vis region of the spectrum on a 0- to 200-μs time scale.

PGE in the presence of CD-1012 (3%) produces a different set of intermediates with red-shifted absorption. Radiolysis of PGE in the presence of CD-1012 does not proceed to form the first intermediate as seen in direct excitation of PGE. Instead, the second intermediate, which is formed initially, reduces iodonium salt to form an ion pair of PGE/CD-1012. Alternatively, solvated electrons could also reduce iodonium salt to produce an aryl iodide, an aryl radical, and an anion of iodonium salt (Figure 18). Reaction of the aryl radical with PGE produces a PGE radical capable of reducing iodonium salt. Hydrogen abstraction from PGE by iodonium anion produces a strong Brönsted acid, which catalyzes the epoxide ring opening and is followed by the polymerization process. Experiments are currently underway to unravel the reaction pathways that are responsible for the observed polymerization process.

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Reza Dabestani,* Illia N. Ivanov* and James M. Sands

7. PERFORMING ORGANIZATION NAME(S) AND ADDRESS(ES)
U.S. Army Research Laboratory
ATTN: AMSRL-WM-MB
Aberdeen Proving Ground, MD 21005-5069

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13. ABSTRACT *(Maximum 200 words)*

Cationic polymerization of epoxy resins can be induced by ultraviolet (UV) or electron beam (E-beam) radiation and proceeds very efficiently in the presence of an appropriate photoinitiator. Although good thermal properties have been obtained for some E-beam cured epoxy resins, other important mechanical properties, such as interlaminar shear strength, fracture toughness, and compression are poor and do not meet aerospace manufacturers materials standards. We have initiated a comprehensive study to investigate the cure kinetics and mechanisms of UV and E-beam cured cationic polymerization of two epoxide-terminated resins (phenyl glycidyl ether (PGE), a monofunctional model compound, and Tactix 123, a difunctional structural resin) cured using a mixed triaryl iodonium hexafluoroantimonate salt (Sartomer's CD-1012) photoinitiator. The objective of this study was to demonstrate that identical reaction conditions and kinetic parameters (e.g., radiation dose, initiator concentration, and reaction temperature) control the physical and chemical properties of final polymeric products, regardless of initiation by UV or E-beam radiation. Additionally, the identification of key parameters that give rise to improved thermal and mechanical properties in E-beam processed resins is sought. Fast kinetic spectroscopy, coupled with high-performance liquid chromatography, was used to elucidate the polymerization mechanism and to identify the reactive intermediates, or molecules, involved in the cure process.

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